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ECSI # 1131

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DEQ AND INTEL SIGN VOLUNTARY CLEANUP AGREEMENT

The Department of Environmental Quality (DEQ) has entered into an agreement with Intel Corporation to conduct a comprehensive environmental investigation to address chlorinated solvents detected in groundwater at its semiconductor chip manufacturing facility in Aloha.

The groundwater contamination resulted from a 1982 spill from a former underground storage tank system at the 38-acre site, located at 3585 S.W. 198th Avenue.

Under this agreement, Intel will determine the full magnitude and extent of hazardous substance contamination at the site. The results of the investigation will be utilized to determine if cleanup is warranted and select an appropriate remedy for the site if necessary.

A copy of the agreement is available upon request by contacting DEQ Project Manager Eric Blischke at DEQ headquarters, (503) 229-6802.

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